# Performance study of <br> <br> Pair Monitor 

 <br> <br> Pair Monitor}

Kazutoshi Ito
Tohoku university
Collaboration
$23^{\text {rd }}$ Sep. 2008

## High precision design

## Introduction

- Pair monitor measures the beam shape at IP, using pair background.
- The same charges with respect to the oncoming beam are scattered with large angle.
- The potential produced by the oncoming beam is a function of beam shape.
- The scattered particles carry the beam information.
- Pair monitor detects the scattered particles.

- Activity of Tohoku group.
- Development of the readout ASIC.

- Simulation study.

Current status of simulation study is shown.

## Simulation setup

- CM energy : 500 GeV
- Beam size : $\left(\sigma_{x}{ }^{0}, \sigma_{y}{ }^{0}, \sigma_{z}{ }^{0}\right)$

$$
=(639 \mathrm{~nm}, 5.7 \mathrm{~nm}, 300 \mu \mathrm{~m})
$$

- Tools : CAIN (e+e- generator) Jupiter (Tracking emulator)
- Magnetic field : 3T with anti-DID.
- Scattered e ${ }^{+}$distribution was studied.


Pair monitor


## Matrix method for beam size reconstruction

- The beam size is reconstructed by the Taylor expansion.


The measurement variables are studied.

## Variable 1: Rmax (sensitive to the horizontal beam size)

$X-Y$ distribution
$\stackrel{\bar{U}}{\bar{U}}$



$R$ distribution seems to depend on the horizontal beam size $\left(\sigma_{\mathrm{x}}\right)$.

## The maximum R was investigated.

## Variable 1:Rmax

- $R_{\text {max }}$ - Radius to contain $99.8 \%$ of all hits.

$R_{\text {max }}$ depends on the horizontal beam size $\left(\sigma_{x}\right)$, dose not depend on the vertical size.


## Variable 2: Ratio (sensitive to $\sigma_{x}$ and $\sigma_{y}$ )

- To derive the beam information, projection to $\phi$-axis is checked. $\phi$ distribution ( $0.5 \times \mathrm{R}_{\max }<\mathrm{R}<0.8 \times \mathrm{R}_{\max }$ )
 $\frac{\bar{c}}{\stackrel{\rightharpoonup}{U}}$


$$
\begin{aligned}
& \text { Projectio, } \\
& \text { to } \phi \text {-axis }
\end{aligned}
$$



## Variable 2: Ratio

- The ratio defined NL/Nall were obtained various beam size. R- $\phi$ distribution for the nominal $\quad$ Ratio $=N_{L} / N_{\text {ALL }}$ (100bunches)




## The ratio depends on the horizontal and vertical beam size ( $\left.\sigma_{x^{\prime}} \sigma_{y}\right)$.

## Variable 3: Total number of hits (sensitive to $\sigma_{x}$ and $\sigma_{x}$ )

- The number of hits also have information of beam shape.

Luminosity(L) $L \propto 1 / \sigma_{x} \sigma_{y}$

Number of hits $\left(\mathrm{N}_{\text {tot }}\right)$ $1 / N_{\text {tot }} \propto 1 / L \propto \sigma_{x} \sigma_{y}$


## 1/Ntot depends on both horizontal and vertical beam size.

## Reconstruction of beam size

- Rmax, Ratio, $1 / N_{\text {tot }}$ were set as the variable term ( $m, A$ and $B$ ).

- Procedure of the beam size reconstruction.
a) $x_{0}=A^{-1} m$
b) $x_{1}=\left[A+x_{0}{ }^{\top} B\right]^{-1} m$
c) $x_{n}=\left[A+x_{n-1}{ }^{\top} B\right]^{-1} m$


## Matrix component





Matrix components are determined by fitting.

## Results of the horizontal beam size reconstruction

measurement of the horizontal beam size ( $\sigma_{\mathrm{x}}$ )

Reconstructed with only ${ }_{4}$ the first order matrx.


Reconstructed with the second order matrix.


Horizontal beam size: $\sigma_{x}^{\text {true }}[\mathrm{nm}]$

- Horizontal beam size can be measured with 2\%.


## Results of the vertical beam size reconstruction

## measurement of the vertical beam size ( $\sigma_{y}$ )

Reconstructed with only the first order matrx. $\frac{20}{0}$


Vertical beam size: $\sigma_{y}{ }^{\text {true }}[\mathrm{nm}]$

Reconstructed with the second order matrx.


Vertical beam size: $\sigma_{y}^{\text {true }}[\mathrm{nm}]$

## Summary

- Pair monitor measures the beam shape at IP.
- Using pair backgrounds.
- The beam size ( $\sigma_{x}, \sigma_{y}$ ) were reconstructed using the matrix of the Taylor expansion (second order).
- There are three measurement variables.
- $R_{\text {max }}$ - sensitive to $\sigma x$.
- Ratio - sensitive to $\sigma x$ and $\sigma y$.
- $1 / N_{\text {tot }}$ - sensitive to $\sigma x$ and $\sigma y$.
- Horizontal beam size $\sigma_{x}$ - resolution : 2\% ( $\sim 14 \mathrm{~nm}$ ).
- Vertical beam size $\sigma_{y}$ - resolution : 3\% ( $\sim 0.2 \mathrm{~nm}$ ).

$$
\begin{aligned}
& m=A x+x^{\top} B x \\
& x=\left[A+x^{\top} B\right]^{-1} m
\end{aligned}
$$

